Freeform Search

Databas	US Patents Full-Text Database US Pre-Grant Publication Full-Text Database JPO Abstracts Database EPO Abstracts Database Derwent World Patents Index IBM Technical Disclosure Bulletins
Term: Display: Generate	L3 and @pd<20000927 25 Documents in Display Format: - Starting with Number 1 C Hit List Hit Count Side by Side Image
	Search Clear Help Logout Interrupt Main Menu Show S Numbers Edit S Numbers Preferences Cases
	Search History

DATE: Thursday, January 30, 2003 Printable Copy Create Case

Set Name side by side	<u>Query</u> e	Hit Count Set Name	
DB=US	PT,PGPB; PLUR=YES; OP=ADJ		result set
<u>L5</u>	5403438[uref]	1	L5
<u>L4</u>	L3 and @pd<20000927	163	<u>L0</u> L4
<u>L3</u>	L2 and ((coat\$3 or cover\$3) near5 resist)		<u>L3</u>
<u>L2</u>	L1 same (pattern\$3 near5 first resist)	434	<u></u> L2
<u>L1</u>	resist same pattern\$3	36779	== L1

END OF SEARCH HISTORY

L Numbe				
•	379	3 (resist near pattern) same cover\$3	DB	Time stamp
	1.		USPAT;	2003/01/30 15:3
			US-PGPUB	3;
			EPO; JPO;	
2			DERWENT	:
	194	((resist near pattern) same cover\$3) same (second near resist)	IBM_TDB	·
	1		USPAT:	2003/01/30 15:39
			US-PGPUB	. =000/01/30 13.38
			EPO; JPO;	'
			DERWENT;	
3	((((resist near pattern) same cover\$3) same (second near resist)) and @pd<20000927	(((resist near pattern) same cover\$3) same (second near resist)) and @pd<20000927	IBM_TDB	
			USPAT;	2002/04/20 45.40
			US-PGPUB;	2003/01/30 15:42
		EPO; JPO;		
			DERWENT;	
	105769	regist come ()	IBM_TDB	
	resist same (pattern	resist same (pattern\$3 or etch\$3)	USPAT;	
	[2003/01/30 15:36
			US-PGPUB;	
			EPO; JPO;	
	2600	1 ,	DERWENT;	
	2698	(resist same (pattern\$3 or etch\$3)) same (second near resist)	IBM_TDB	
		(occord flear resist)		2003/01/30 12:03
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	933	((resist same (pattern\$3 or etch\$3)) same (second near	IBM_TDB	
- 1	ł	resist)) same (coat\$3 or cover\$3)	USPAT;	2003/01/30 13:06
1		/ (** 4.40 or cover40)	US-PGPUB;	13.00
ļ			EPO; JPO;	1
- 1	1		DERWENT;	
1	645	(((resist same (nattern\$2 or atal \$0))	IBM_TDB	
1		(((resist same (pattern\$3 or etch\$3)) same (second near resist)) same (coat\$3 or expension)	USPAT;	2003/01/30 13:11
1	1	resist)) same (coat\$3 or cover\$3)) and @pd<20000927	US-PGPUB:	2003/01/30 13:11
}	Í		EPO; JPO;	
			DERWENT;	1
1	15	((((resist same /nottor=02)	IBM_TDB	
1	- 1	((((resist same (pattern\$3 or etch\$3))) same (second near resist)) same (coat\$3 or cours*2))	USPAT;	2002/04/02 15 5
			US-PGPUB;	2003/01/30 12:09
	1	((polysilesesquioxane or "SOG") same etch\$3)	EPO; JPO;	
1		·	DERWENT;	
1	193	((resist some /	IBM_TDB	ļ
1	.00	resist)) same ((coat\$3 or cover\$3)) same (second near		00004044
			LIS DODUD	2003/01/30 13:08
	'	or "SOG" or metal))	US-PGPUB;	į
}			EPO; JPO;	
	122	March 1	DERWENT;	1
	133 (((resist same (pattern\$3 or etch\$3)) same (second near	IBM_TDB	1
			USPAT;	2003/01/30 13:12
	0	or "SOG" or metal))) and @pd<20000927	O2-PGPOB;	
	ł	5, = =000021	EPO; JPO;	
			DERWENT;	
			IBM_TDB	ł